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PATENT NUMBER and
ISSUE DATE

U.S. UTILITY Patent Application

APPL NUM 10068282	FILING DATE 02/04/2002	CLASS 257	SUBCLASS 311	GAU 2811	EXAMINER Duda
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APPL NUM 10068282	FILING DATE 02/04/2002	CLASS 257	SUBCLASS	GAU 1756	EXAMINER DUDA, K
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****APPLICANTS:** Hudson Eric; Sadjadi Reza; Ren Daxing; Chen Wan-Lin; Keil Douglas; Cirigliano Peter;

****CONTINUING DATA VERIFIED:**

**** FOREIGN APPLICATIONS VERIFIED:**

PG-PUB	DO NOT PUBLISH <input type="checkbox"/>	RESCIND <input type="checkbox"/>
Foreign priority claimed <input type="checkbox"/> yes <input type="checkbox"/> no 35 USC 119 conditions met <input type="checkbox"/> yes <input type="checkbox"/> no Verified and Acknowledged Examiners's initials		ATTORNEY DOCKET NO LAM1P161/P0915
TITLE : Post-development treatment of patterned photoresist to promote cross-linking of polymer chains		

U.S. DEPT. OF COMM./PAT. & TM.-PTO-436L (Rev. 12-94)

NOTICE OF ALLOWANCE MAILED		CLAIMS ALLOWED	
		Total Claims	Print Claim for O.G.
ISSUE FEE		DRAWING	
Amount Due	Date Paid	Sheets Drwg.	Figs. Drwg. Print Fig.
<input type="checkbox"/> TERMINAL DISCLAIMER		Application Examiner	
		PREPARED FOR ISSUE	
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